



In the United States Patent and Trademark Office

In re Application of:

Neil F. Haley, et al

RADIATION-SENSITIVE
COMPOSITION CONTAINING A
RESOLE RESIN, A NOVOLAC
RESIN, AN INFRARED ABSORB-
ER AND A TRIAZINE AND USE
THEREOF IN LITHOGRAPHIC
PRINTING PLATES

Serial No. 212,434

Filed 14 March 1994

Honorable Assistant Commissioner For Patents
Washington, D.C. 20231

Sir:

AMENDMENT AFTER FINAL REJECTION

In response to the Office Action of August 7,
1995, please amend the above-identified application as
follows:

In the Claims:

Please amend claim 1 as follows:

1. (Amended) A radiation-sensitive
composition useful for the preparation of an imaging
layer of a lithographic printing plate that is
sensitive to both ultraviolet and infrared radiation
and capable of functioning in either a positive-working
or negative-working manner; said radiation-sensitive
composition comprising (1) a resole resin, (2) a
novolac resin, (3) a haloalkyl-substituted S-triazine,
and (4) an infrared absorber in amounts such that the
solubility of said imaging layer in aqueous alkaline
developing solution is reduced in exposed areas and
increased in unexposed areas by the steps of imagewise
exposure to activating radiation and heating.

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RESPONSE UNDER 37C.F.R. 1.116
-EXPEDITED PROCEDURE-
EXAMINING GROUP 1507

Group Art Unit: 1507

Examiner: L. Weiner

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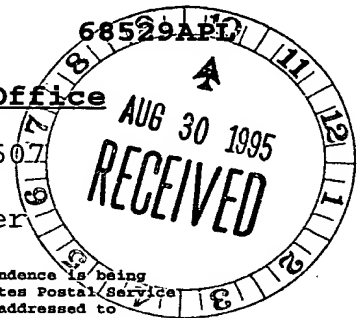
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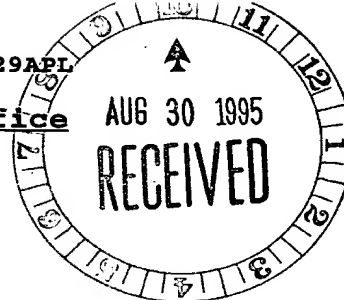
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RADIATION-SENSITIVE COMPOSITION
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Alfred P. Lorenzo

Name

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22.503

Reg. No.

AUGUST 21, 1995

Date of Signature

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Honorable Assistant Commissioner for Patents
Washington, D.C. 20231

Transmitted herewith is a Response in the above-identified application:

- ☒ No additional fee is required.
☐ The fee has been calculated as shown below:

The filing fee has been calculated as shown below:

	(Col. 1)		(Col. 2)	(Col. 3)	OTHER THAN A SMALL ENTITY	
	CLAIMS REMAINING AFTER AMENDMENT		* HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL		MINUS			X 22	\$
INDEP		MINUS			X 74	\$
	FIRST PRESENTATION OF MULTIPLE DEPENDENT CLAIM				+ 230	\$
					TOTAL	\$

* The "Highest Number Previously Paid For" (Total or Independent) is the highest number found from the equivalent box in Col. 1 of a prior amendment or the number of claims originally filed.

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☒ Any additional filing fees required under 37 CFR 1.16.

☐ Any patent application processing fees under 37 CFR 1.17.
(For Extensions of Time and other Petitions to the Commissioner)

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